

Vicinal Surface with Langmuir Adsorption: A Decorated Restricted Solid-on-solid Model

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(February 1, 2008)

We study the vicinal surface of the restricted solid-on-solid model coupled with the Langmuir adsorbates which we regard as two-dimensional lattice gas without lateral interaction. The effect of the vapor pressure of the adsorbates in the environmental phase is taken into consideration through the chemical potential. We calculate the surface free energy f , the adsorption coverage Θ , the step tension γ , and the step stiffness $\tilde{\gamma}$ by the transfer matrix method combined with the density-matrix algorithm. Detailed step-density-dependence of f and Θ is obtained. We draw the roughening transition curve in the plane of the temperature and the chemical potential of adsorbates. We find the multi-reentrant roughening transition accompanying the inverse roughening phenomena. We also find quasi-reentrant behavior in the step tension.

PACS numbers: 05.70.Np, 68.35.Rh, 05.50.+q, 68.35.Md

I. INTRODUCTION

The adsorption effect has been an important subject of study in wide area of surface science [1–5]. As for the steps on the surface, either with or without adsorption, detailed experiments in various length scales [6–12] has become possible due to the development of the surface observation technique such as STM (scanning-tunneling microscopy) [13], LEEM (low-energy electron microscopy) [14] and REM (reflection electron microscopy) [15]. The length scale of STM is the order of nanometer, while that of LEEM and REM is more than hundreds nanometer. Then, the importance of the detailed statistical mechanical study connecting observations in different length scales has been increasing.

As for the statistical mechanical study of vicinal surface with adsorption, however, reliable calculations have been difficult due to the criticality of the vicinal surface. In the present paper, to overcome the difficulty, we use the product wave-function renormalization group (PWFRG) algorithm [16–18] which is a variant of the density matrix renormalization group (DMRG) algorithm [19]. The efficiency of the method for the vicinal surface problem has been demonstrated in Ref. [16,17,20]

We make statistical mechanical calculations on the vicinal surface of the restricted solid-on-solid model coupled with the Langmuir adsorbates which we regard as two-dimensional lattice gas without lateral interaction. We aim at clarifying the “entropic effect” for surfaces and steps caused by adsorbates. The results are applicable to realistic vicinal surfaces if the temperature is high enough to neglect the interaction between the adsorbates, or the interaction itself is negligibly small.

This paper is organized as follows. In §II, we introduce a “decorated” RSOS model where the ledge formation energy is locally modified by the presence of the adsorbate atom on the ledge. After tracing out the lattice-gas degrees of freedom, we obtain the effective RSOS model which we show in §III. In §IV, we give phase diagram associated with the roughening transition. We show that the multi-reentrant roughening transition occurs. Calculated results for surface free energy per projected area f , surface gradient p , magnetization (adsorption coverage Θ) M , step tension γ , and step stiffness $\tilde{\gamma}$ are given in §V. Quasi-reentrant behavior of step tension is also shown. In §VI, we give summary of the paper.

II. MODEL HAMILTONIAN

We consider the square lattice where the position of each site i is expressed in terms of a pair of integers as $i = (m, n)$. To each site i we assign the integer height variable $h_i (= h(m, n))$. An Ising spin variable $\sigma_x(m, n)$ or $\sigma_y(m, n)$ representing the adsorbate atom is assigned to each lattice edge (σ_x for vertical edge, and σ_y for horizontal edge). The Hamiltonian of the decorated RSOS model is written as follows:

$$\begin{aligned} \mathcal{H} = & \sum_{m,n} \{ \epsilon [1 - \alpha \sigma_y(m, n)] \cdot |h(m+1, n) - h(m, n)| \\ & + \epsilon [1 - \alpha \sigma_x(m, n)] \cdot |h(m, n+1) - h(m, n)| \} \\ & - \eta \sum_{m,n} [h(m+1, n) - h(m, n)] \\ & - H \sum_{m,n} [\sigma_x(m, n) + \sigma_y(m, n)] \end{aligned} \quad (2.1)$$

$$= \mathcal{H}_{\text{RSOS}} + \mathcal{H}_{\text{L}} + \mathcal{H}_{\text{int}}, \quad (2.2)$$

where

$$\begin{aligned} \mathcal{H}_{\text{RSOS}} &= \sum_{\langle i,j \rangle} \epsilon |h_i - h_j| \\ &\quad - \eta \sum_{m,n} [h(m+1, n) - h(m, n)], \\ \mathcal{H}_{\text{L}} &= -H \sum_{m,n} [\sigma_x(m, n) + \sigma_y(m, n)], \\ \mathcal{H}_{\text{int}} &= - \sum_{m,n} \epsilon \alpha [\sigma_y(m, n) \cdot |h(m+1, n) - h(m, n)| \\ &\quad + \sigma_x(m, n) \cdot |h(m, n+1) - h(m, n)|]. \end{aligned} \quad (2.3)$$

The Hamiltonian $\mathcal{H}_{\text{RSOS}}$ describing the surface configuration of the mother crystal is that of the restricted solid-on-solid (RSOS) model [21] on the square lattice with nearest-neighbor (nn) interactions; ϵ is the “bare” ledge energy, and η the Andreev field [22] to make surface tilt [20,23]. In (2.2) and (2.3), the height difference $h_i - h_j$ ($\equiv \Delta h_{ij}$) is restricted to be $\Delta h_{ij} = 0, \pm 1$ (RSOS condition), which is a reasonable simplification because configurations with large $|\Delta h_{ij}|$ are energetically unfavorable.

The Hamiltonian $\mathcal{H}_{\text{L}}$ describes a system of free Ising spins ($\sigma = \pm 1$) on the edges of the square lattice (Fig. 1). We regard these free spins as the Langmuir adsorbates in a monolayer adsorption without lateral interaction. The adsorption energy is represented by H . Since the adsorbates are situated at the “bridge” sites, the total number of adsorption sites are twice as many as the total number of the lattice points of the RSOS model.

The Hamiltonian $\mathcal{H}_{\text{int}}$ represents the interaction between the RSOS system and the adsorbate, with α being a parameter describing the local change of ledge energy caused by a spin (an adsorbate atom) [24]. In what follows, we assume $\alpha > -1$.

The decorated RSOS model is a special case ($J = 0$) of the RSOS-Ising coupled model [23,25] where the interaction between adsorbates is taken into account.

Since the lattice-gas representation is physically more natural for description of the adsorbates than the spin representation, we map the decorated RSOS to the equivalent RSOS-lattice-gas system. We introduce the lattice gas (LG) variable $c = \{0, 1\}$ by $c = (\sigma + 1)/2$; $\sigma = 1$ corresponds to the presence of an adsorbate ($c = 1$), and $\sigma = -1$ to the absence of the adsorbate ($c = 0$). Then $\mathcal{H}$ (eq. (2.2)) is rewritten in terms of the LG variable as follows:

$$\begin{aligned} \mathcal{H}_{\text{LG}} &= \sum_{\langle i,j \rangle} \tilde{\epsilon} |h_i - h_j| - \eta \sum_{m,n} [h(m+1, n) - h(m, n)] \\ &\quad - \mu \sum_{m,n} [c_x(m, n) + c_y(m, n)] \\ &\quad - \sum_{m,n} \tilde{\epsilon} \tilde{\alpha} [c_y(m, n) \cdot |h(m+1, n) - h(m, n)| \\ &\quad + c_x(m, n) \cdot |h(m, n+1) - h(m, n)|] \end{aligned}$$

$$\begin{aligned} &+ c_x(m, n) \cdot |h(m, n+1) - h(m, n)| \\ &+ \text{const.}, \end{aligned} \quad (2.4)$$

where

$$\tilde{\epsilon} = \epsilon(1 + \alpha), \quad \tilde{\alpha} = \frac{2\alpha}{1 + \alpha}, \quad \mu = 2H, \quad (2.5)$$

$$|h_i - h_j| = \{0, 1\}. \quad (2.6)$$

The parameter $\tilde{\epsilon}$ represents the microscopic ledge energy of the “clean” (i. e., without adsorbate) surface, μ the surface chemical potential, and $\tilde{\alpha}$ the redefined coupling parameter. From (2.4) we see that, for $\tilde{\alpha} > 0$ (resp. $\tilde{\alpha} < 0$), the adsorbate makes the microscopic ledge energy smaller (resp. larger) than that of the clean surface, which will lead to rougher (resp. smoother) surface with larger (resp. smaller) population of adsorbates on the ledges (Fig. 1).

Physically, the chemical potential μ consists of two terms,

$$\mu = \epsilon_{\text{ads}} + k_{\text{B}} T \ln P, \quad (2.7)$$

where ϵ_{ads} is the adsorption energy which depends on the combination of the atomic species of the adsorbate/substrate, and P is the environmental vapor pressure of adsorbate gas in thermal equilibrium with the surface (k_{B} : Boltzmann constant, T : temperature). Introducing P_0 by $\epsilon_{\text{ads}} = -k_{\text{B}} T \ln P_0$, we have

$$\mu = k_{\text{B}} T \ln(P/P_0) = 2H. \quad (2.8)$$

We should note the following symmetry of the system: the Hamiltonian (2.2) is invariant under the change $(\alpha, \sigma_x, \sigma_y, H) \leftrightarrow (-\alpha, -\sigma_x, -\sigma_y, -H)$. Although the lattice gas representation is more natural than the Ising-spin representation, the latter has a merit that this symmetry is apparently seen. In the following sections, we adopt the Ising-spin representation. Results in the lattice-gas representation are also shown if necessary.

III. EFFECTIVE RSOS HAMILTONIAN

Since each nn height difference Δh is restricted to $\{0, \pm 1\}$, we have an identity $F(|\Delta h|) = F(0)\delta_{\Delta h,0} + F(1)(\delta_{\Delta h,1} + \delta_{\Delta h,-1})$ with $\delta_{i,j}$ being the Kronecker’s delta. Using this identity, we can exactly decimate spin variables $\{\sigma\}$ in $\mathcal{H}$ to obtain the effective Hamiltonian $\mathcal{H}^{\text{eff}}$ as follows ($\beta = 1/(k_{\text{B}} T)$):

$$\begin{aligned} &\sum_{\{\sigma(m,n)\}} \exp(-\beta \mathcal{H}) \\ &= (2 \cosh \beta H)^{Nz/2} \exp(-\beta \mathcal{H}^{\text{eff}}), \end{aligned} \quad (3.1)$$

$$\begin{aligned} \beta \mathcal{H}^{\text{eff}} &= \sum_{\langle i,j \rangle} \beta \epsilon^{\text{eff}} |h_i - h_j| \\ &\quad - \eta \sum_{m,n} [h(m+1, n) - h(m, n)], \end{aligned} \quad (3.2)$$

$$\epsilon^{\text{eff}} = \epsilon - k_{\text{B}} T \ln \left[\frac{\cosh(\beta \alpha \epsilon + \beta H)}{\cosh \beta H} \right], \quad (3.3)$$

where N is the number of lattice point in the RSOS system and z ($= 4$) is the coordination number. Hence the decorated RSOS system is equivalent to a non-decorated RSOS system with the effective ledge energy ϵ^{eff} .

In Fig. 2, we show temperature and chemical potential dependence of effective ledge energy ϵ^{eff} . We should note that, at sufficiently low temperatures, ϵ^{eff} is well approximated by

$$\epsilon^{\text{eff}} = \epsilon(1 - |\alpha + H/\epsilon| + |H/\epsilon|). \quad (3.4)$$

We rewrite the ϵ^{eff} by using $\tilde{\epsilon}$ and $\tilde{\alpha}$ in (2.5) as follows:

$$\epsilon^{\text{eff}} = \tilde{\epsilon}(1 - \tilde{\alpha}/2) - k_B T \ln \left[\frac{\cosh(\beta \tilde{\alpha} \tilde{\epsilon}/2 + \beta H)}{\cosh \beta H} \right]. \quad (3.5)$$

At low temperatures, we have

$$\epsilon^{\text{eff}} = \tilde{\epsilon}(1 - \tilde{\alpha}/2 - |\tilde{\alpha}/2 + H/\tilde{\epsilon}| + |H/\tilde{\epsilon}|). \quad (3.6)$$

In Fig. 3, we show temperature and chemical potential dependence of ϵ^{eff} in the lattice-gas representation.

At low temperatures where the entropy effect of adsorbate configurations almost vanishes, ϵ^{eff} should become approximately $\tilde{\epsilon}(1 - \tilde{\alpha}\Theta)$. Therefore, from eq. (3.6), we have the low-temperature expression of Θ :

$$\Theta = \frac{1}{2} + \frac{1}{\tilde{\alpha}}(|\tilde{\alpha}/2 + H/\tilde{\epsilon}| - |H/\tilde{\epsilon}|). \quad (3.7)$$

IV. MULTI-REENTRANT ROUGHENING TRANSITION

A. Determination of roughening transition temperature

The roughening transition temperature of the original (non-decorated) RSOS model is known to be given by [26] $\epsilon/(k_B T_R^{\text{RSOS}}) = 0.633 \dots \equiv \zeta_R$. Therefore, T_R of the decorated RSOS model (the surface with Langmuir adsorption) is determined from $\epsilon^{\text{eff}}/(k_B T_R) = \zeta_R$; when $\epsilon^{\text{eff}}/k_B T > \zeta_R$ (resp. $\leq \zeta_R$), the surface is smooth (resp. rough). From Eq. (3.3), we obtain an equation,

$$\zeta_R = \frac{\epsilon}{k_B T_R} - \ln \left\{ \frac{\cosh[(\alpha\epsilon + H)/k_B T_R]}{\cosh(H/k_B T_R)} \right\}, \quad (4.1)$$

which determines T_R (see Fig. 4). For instance, at $\alpha = 0.5$ and $H = 0$, we obtain $k_B T_R/\epsilon = 1.446$. From Eq. (4.1) we have

$$\frac{H}{k_B T_R} = \frac{1}{2} \ln \frac{\exp[\zeta_R - (1 + \alpha)\epsilon/(k_B T_R)] - 1}{1 - \exp[\zeta_R - (1 - \alpha)\epsilon/(k_B T_R)]}, \quad (4.2)$$

which allows us to draw the critical line in the $H - T$ plane, as shown in In Fig. 5.

In $H \rightarrow \infty$ limit, we have $\langle \sigma \rangle$ (magnetization) $\rightarrow 1$; all of the ledge sites are covered by adsorbates ($\Theta = 1$)

(Fig. 4 (a)). In this limit, ϵ^{eff} becomes $\epsilon(1 - \alpha)$ from which the roughening transition temperature becomes $k_B T_R/\epsilon = (1 - \alpha)/\zeta_R$. In $H \rightarrow -\infty$ limit, we have $\langle \sigma \rangle \rightarrow -1$, which corresponds to the clean surface ($\Theta = 0$). In this limit, ϵ^{eff} converges to $\epsilon(1 + \alpha) = \tilde{\epsilon}$, and the roughening transition temperature becomes $k_B T_R/\epsilon = (1 + \alpha)/\zeta_R$.

B. Multi-reentrant transition

Around $\alpha = 1$, there occurs reentrant phase transition in a range of H (Fig. 5 (b) and (c)). At $\alpha = 1$, as we decrease temperature fixing $H/\epsilon = 0.01$, the system cause phase transition twice: rough $\rightarrow$ smooth $\rightarrow$ rough (Fig. 4 (b) and 5 (b)). This reentrant transition is similar to what has been known in the 2D frustrated Ising models [27,28].

At $\alpha = 1.1$ and $H/\epsilon = -0.0735$, the phase transition occurs three times as we decrease temperature, which can be seen from Fig. 4 (c) and 5 (c); the system shows “multi-reentrant” roughening transition, which has not been known previously. The origin of this phenomenon is the non-trivial behavior of ϵ^{eff} in the parameter region around $\alpha = 1$ and $H = 0$. In this region, ϵ^{eff} varies sensitively with H , making the critical curve non-monotonic.

It should be noted that the (multi-) reentrant behavior accompanies the inverse roughening [29] proposed for CsCl type crystal surface. Hence, our decorated RSOS model is a different but physically realizable system showing the inverse roughening.

V. BEHAVIOR OF THE VICINAL SURFACE

A. Universal behavior of the vicinal surfaces

The exact mapping to the ordinary RSOS system given by (3.1)~(3.3) implies that the vicinal surface of the decorated RSOS model belongs to the Gruber-Mullins-Pokrovsky-Talapov (GMPT) universality class [30–35] below the roughening temperature. This means that, in spite of the presence of the adsorbates, the coarse-grained vicinal surface is well described in terms of “effective terraces”, “effective steps” and “effective kinks” allowing us to take the terrace-step-kink (TSK) picture.

The surface free energy (per projected area) $f = f(\rho)$ (ρ : step density) has the expansion characteristic to the GMPT universality class,

$$f(\rho) = f(0) + \gamma\rho + B\rho^3 + O(\rho^4), \quad (5.1)$$

where γ is the step tension and B is the step interaction coefficient. When the system is not isotropic, γ and B depend on the mean running direction of steps. By θ , we denote the angle between one of the crystal axes on the facet plane and the mean running direction of steps. [36] We should then write $\gamma = \gamma(\theta)$ and $B = B(\theta)$. There

exists the following universal relation between $\gamma(\theta)$ and $B(\theta)$ [37,38] (which leads to the universal Gaussian curvature jump at the facet edge [37,38]) for systems where the step-step interaction is short-ranged:

$$B(\theta) = \frac{\pi^2}{6} \frac{(k_B T)^2}{\tilde{\gamma}(\theta)}, \quad (5.2)$$

where $\tilde{\gamma}(\theta)$ defined by

$$\tilde{\gamma}(\theta) = \gamma(\theta) + \partial^2 \gamma(\theta) / \partial \theta^2 \quad (5.3)$$

is the step stiffness.

B. Calculation of surface and step quantities by PWFRG method

From the Hamiltonian (2.2) and the partition function Z associated with it, we obtain the Andreev surface free energy $\tilde{f}(\vec{\eta})$ as

$$\tilde{f}(\vec{\eta}) = -\frac{1}{N} k_B T \ln Z, \quad (5.4)$$

where $\vec{\eta} = (\eta_x, \eta_y)$ is the Andreev field. As was shown by Andreev [22], $\tilde{f}(\vec{\eta})$ directly gives the equilibrium crystal shape (ECS). In the present study, we set $\eta_x = \eta$ and $\eta_y = 0$; $\tilde{f}(\eta) - \eta$ curve can be regarded as the profile of ECS near (001) facet along the x -direction, and the facet size corresponds to the step tension $\gamma(0)$ [39].

To calculate RHS of Eq.(5.4), we treat the system by the transfer-matrix method. Since the decorated RSOS model reduces to the original RSOS model, we can utilize the representation as the 19-state vertex model [21,40] to make the transfer-matrix. We can also use the decorated RSOS model itself by mapping the model to a “decorated” vertex model (Fig. 1) [23,25] with $19 \times 16 = 304$ non-zero vertex weights (304-vertex model). For approximate diagonalization of the transfer matrix, we employ the PWFRG method [16–18,20] which is a variant of White’s density matrix renormalization group (DMRG) method [19].

From $\tilde{f}(\vec{\eta})$, we can calculate $f(\vec{p})$ (the surface free energy with fixed surface gradient vector $\vec{p}$), through the Legendre transformation:

$$f(\vec{p}) = \tilde{f}(\vec{\eta}) + \vec{p}\vec{\eta}. \quad (5.5)$$

We should recall the following thermodynamical equations associated with the Legendre transformation [22]:

$$p_x = -\partial \tilde{f}(\vec{\eta}) / \partial \eta_x, \quad p_y = -\partial \tilde{f}(\vec{\eta}) / \partial \eta_y, \quad (5.6)$$

$$\eta_x = \partial f(\vec{p}) / \partial p_x, \quad \eta_y = \partial f(\vec{p}) / \partial p_y. \quad (5.7)$$

In the actual calculation, we obtain $p = p_x(\eta)$ as the statistical average

$$p(\eta) = \langle \Delta h_x(m, n) \rangle = \langle h(m+1, n) - h(m, n) \rangle. \quad (5.8)$$

By sweeping the field η , we obtain a $p - \eta$ curve. In order to obtain γ and $\tilde{\gamma}$, we use the relations (5.1) and (5.2). Substituting Eq. (5.1) into Eq. (5.7), we have (for $\theta = 0$)

$$\eta = \gamma(0) + 3B(0)|p|^2 + (\text{higher order}). \quad (5.9)$$

Hence, we obtain $\gamma(0)$ and $B(0)$ by performing the least-square fitting of the $\eta - p$ curve (inverted $p - \eta$ curve). The step stiffness $\tilde{\gamma}(0)$ is calculated from $B(0)$ through Eq. (5.2).

C. Surface free energies and surface gradient

In Fig. 6 (b), we show $\tilde{f}(\eta)$ ($\eta_x = \eta, \eta_y = 0$) at several temperatures for $\alpha = 0.5$ and $H = 0$. The $p - \eta$ curves are shown in Fig. 7. The roughening temperature is determined by Eq. (4.1) as $k_B T_R / \epsilon = 1.446$ (§IV). At temperatures lower than T_R , the square-root behavior $p \sim (\eta - \gamma)^{1/2}$ characteristic to the GMPT universality class is seen.

From Eq. (5.5), we obtain $f(p)$ which is shown in Fig. 6 (a). At $T < T_R$, $f(p) - p$ curve has a cusp at $p = 0$.

D. Adsorbate concentration

The magnetization M is calculated as $M = (M_x + M_y)/2$ where $M_x = \langle \sigma_x \rangle$ and $M_y = \langle \sigma_y \rangle$ are directly calculated by the PWFRG method. The adsorption coverage Θ is given by $\Theta = (M + 1)/2$. We have the following expressions for M_x and M_y :

$$\begin{aligned} M_x &= \langle \sigma_x \rangle = \frac{\sum_{\{h(i,j)\}} \tanh \beta H_x^{\text{eff}}(i,j) \exp[-\beta \mathcal{H}^{\text{eff}}]}{\sum_{\{h(i,j)\}} \exp[-\beta \mathcal{H}^{\text{eff}}]}, \\ &\equiv \langle \tanh \beta H_x^{\text{eff}}(i,j) \rangle_h, \\ M_y &= \langle \sigma_y \rangle = \langle \tanh \beta H_y^{\text{eff}}(i,j) \rangle_h. \end{aligned} \quad (5.10)$$

Here

$$\begin{aligned} H_x^{\text{eff}}(i,j) &= H + \epsilon \alpha |\Delta h_y(i,j)|, \\ \Delta h_y(i,j) &= h(i,j+1) - h(i,j), \\ H_y^{\text{eff}}(i,j) &= H + \epsilon \alpha |\Delta h_x(i,j)|, \\ \Delta h_x(i,j) &= h(i+1,j) - h(i,j), \end{aligned} \quad (5.11)$$

can be interpreted as the effective local (magnetic) fields modulated by surface undulation.

Since Δh takes 0 or ± 1 , we have the identity $\langle F(|\Delta h|) \rangle = F(0) + (F(1) - F(0)) \langle |\Delta h| \rangle$, which allows us to express M_x and M_y as

$$\begin{aligned} M_x &= \tanh \beta H + [\tanh \beta (H + \epsilon \alpha) \\ &\quad - \tanh \beta H] \langle |\Delta h_y(i,j)| \rangle_h, \\ M_y &= \tanh \beta H + [\tanh \beta (H + \epsilon \alpha) \\ &\quad - \tanh \beta H] \langle |\Delta h_x(i,j)| \rangle_h. \end{aligned} \quad (5.12)$$

We should note the relations,

$$\begin{aligned} < |\Delta h_y(i, j)| >_h = < \delta_{\Delta h_y(i, j), 1} >_h \\ &+ < \delta_{\Delta h_y(i, j), -1} >_h, \\ < |\Delta h_x(i, j)| >_h = < \delta_{\Delta h_x(i, j), 1} >_h \\ &+ < \delta_{\Delta h_x(i, j), -1} >_h, \end{aligned} \quad (5.13)$$

where $\delta_{i,j}$ is the Kronecker's delta. Then, we have

$$\begin{aligned} p_y &= < \delta_{\Delta h_y(i, j), 1} >_h - < \delta_{\Delta h_y(i, j), -1} >_h = 0, \\ p_x &= < \delta_{\Delta h_x(i, j), 1} >_h - < \delta_{\Delta h_x(i, j), -1} >_h = p. \end{aligned} \quad (5.14)$$

Substituting Eq. (5.13) and Eq. (5.14) into Eq. (5.12), we obtain

$$\begin{aligned} M_x &= \tanh \beta H + [\tanh \beta (H + \epsilon \alpha) \\ &\quad - \tanh \beta H] \cdot 2 < \delta_{\Delta h_y(i, j), -1} >_h, \\ M_y &= \tanh \beta H + [\tanh \beta (H + \epsilon \alpha) \\ &\quad - \tanh \beta H] (p + 2 < \delta_{\Delta h_x(i, j), -1} >_h). \end{aligned} \quad (5.15)$$

In Fig. 8, we show p -dependence of M_x and M_y for $\alpha = 0.5$ and $H = 0$. As is seen from the figure, $< \delta_{\Delta h_y(i, j), -1} >_h$ depends on p , taking maximum around $p \sim 0.5$. At $p = 0$, $< \delta_{\Delta h_y(i, j), -1} >_h (= < \delta_{\Delta h_x(i, j), -1} >_h)$ is small because the surface is in the smooth phase; while at $p = 1$, $< \delta_{\Delta h_y(i, j), -1} >_h = 0$ due to the geometrical restriction in the RSOS model. Therefore, $< \delta_{\Delta h_y(i, j), -1} >_h$ should have a maximum in between $p = 0$ and $p = 1$.

E. Step tension and step stiffness

At low temperatures, step quantities of the RSOS model are well approximated by the interface quantities of 2D Ising model [20]. Using the Ising-model results, we have the following approximate analytic expressions of γ and $\tilde{\gamma}$ [41,42],

$$\gamma = \epsilon^{\text{eff}} - k_B T \ln [\tanh(\epsilon^{\text{eff}}/2k_B T)], \quad (5.16)$$

$$\begin{aligned} \tilde{\gamma} &= k_B T \sinh(\gamma/k_B T) \\ &= k_B T [\exp(\epsilon^{\text{eff}}/k_B T) \tanh(\epsilon^{\text{eff}}/(2k_B T)) \\ &\quad - \exp(-\epsilon^{\text{eff}}/k_B T) \coth(\epsilon^{\text{eff}}/(2k_B T))]/2. \end{aligned} \quad (5.17)$$

In Fig. 9 and 10, we show the temperature dependence of step tension and step stiffness given by Eq. (5.16) and (5.17) for several values of H (or, equivalently, $\mu/2$). We see that the Ising-model expressions (5.16) and (5.17) agree very well with the PWFRG calculation at low temperatures.

In the temperature dependence of γ , there is an interesting property that γ exhibits the quasi-reentrant behavior; there appears a temperature region where γ increases as we raise the temperature, although γ is usually a decreasing function of the temperature. Accordingly, γ has a maximum at a temperature above which γ decreases again as we raise the temperature. This behavior

of γ is what we call the quasi-reentrant behavior of a step, which can be seen in the 2D frustrated Ising models [28]. Since the size of the facet in the ECS is proportional to the step tension, the facet size should also exhibit the quasi-reentrant behavior [28].

The step tension and step stiffness in the lattice-gas representation are given in Fig. 11 and 12, respectively. When $\alpha = 0.5$ (Fig. 11 (b) and Fig. 12 (b)), γ and $\tilde{\gamma}$ of the surface with adsorption are smaller than those of the clean surface; the step fluctuation width which is inversely proportional to $\tilde{\gamma}$ [42,43] becomes larger, and T_R becomes lower. As the vapor pressure P is raised, γ and $\tilde{\gamma}$ become smaller because the increase of adsorbate concentration causes the decrease of ϵ^{eff} (Fig. 3 (b)). At $\alpha = -0.5$, γ and $\tilde{\gamma}$ of adsorbed surface are larger than those of clean surface, and T_R becomes higher. As we raise P , γ and $\tilde{\gamma}$ grows, because the increase of adsorbate concentration causes the increase of ϵ^{eff} (Fig. 3 (e)).

VI. SUMMARY

In this paper, we have discussed the Langmuir adsorption effect on the vicinal surface below the roughening temperature, in terms of the restricted solid-on-solid (RSOS) model coupled with the Ising spins. We have shown that this “decorated” RSOS model reduces to the ordinary RSOS model with the effective ledge energy. The effective ledge energy depends on temperature T and the chemical potential μ of the adsorbates, which is caused by the change of the adsorbate concentration.

We have found that, in a parameter region, there occurs novel multi-reentrant roughening transition. By employing the product-wave-function renormalization group (PWFRG) method, we have calculated thermodynamical quantities associated with the vicinal surface of the model. We have also obtained quasi-reentrant behavior in the temperature dependence of step tension in a wide area of the phase diagram.

We should give a comment on a related study made previously. In Ref. [44], a similar modeling is adopted for the absolute SOS model and the discrete Gaussian model, where the adsorption effect on the roughening temperature is discussed in terms of the approximate renormalization group approach (vicinal surface problem is not discussed). One of the merits of our RSOS modeling is that exact renormalization of coupling constant is available, which allows us semi-analytical treatment of the problem.

ACKNOWLEDGMENTS

This work was partially supported by the “Research for the Future” Program from The Japan Society for the Promotion of Science (JSPS-RFTF97P00201) and by the

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- [36] If we set up the xy coordinates on the facet plane so that the y -axis corresponds to a crystal axis, surface direction of a vicinal surface is specified by the surface gradient vector $\vec{p} = (p_x, p_y)$ where p_x (resp. p_y) is the mean surface gradient along the x - (resp. y -) direction. The step density ρ relates to $\vec{p}$ by $\rho = |\vec{p}|/a_h = \sqrt{p_x^2 + p_y^2}/a_h$ where a_h is the height of a single step. The mean running direction angle θ of the steps relates to $\vec{p}$ as $\vec{p} = |\vec{p}|(\cos \theta, \sin \theta)$. We regard the free energy f as a function of the gradient vector $\vec{p} = (p_x, p_y)$, allowing us to write $f = f(\vec{p})$. In the present paper, we take the units where $a_h = 1$. In the actual calculation, we consider the case where the steps are running along the y -direction ($p_y = 0$).
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FIG. 1. (a) RSOS heights ($h_1, \dots, h_4$) and the edge variables in the mapped vertex model. (b) A vertex and leg variables. (c) A vertex decorated by spins which are represented by circles.

FIG. 2. Temperature dependence of the effective coupling constant ϵ^{eff} in the spin representation (Eq. (3.3)). (a) $\alpha = 0.1$. (b) $\alpha = 0.5$. (c) $\alpha = 1$. In each figure, we draw the line for $H/\epsilon = 0.2$ (dashed), $H/\epsilon = 0.1$ (dotted), $H/\epsilon = 0$ (solid), $H/\epsilon = -0.1$ (two-dot dashed), and $H/\epsilon = -0.2$ (dot dashed).

FIG. 3. Temperature dependence of the effective ledge energy ϵ^{eff} in the lattice gas representation (Eq. (3.5)). In each figure, we draw the line for $H/\tilde{\epsilon} = 0.2$ (dashed), $H/\tilde{\epsilon} = 0.1$ (dotted), $H/\tilde{\epsilon} = 0$ (solid), $H/\tilde{\epsilon} = -0.1$ (two-dot dashed), and $H/\tilde{\epsilon} = -0.2$ (dot dashed). (a) $\tilde{\alpha} = 0.2$. (b) $\tilde{\alpha} = 0.5$. (c) $\tilde{\alpha} = 1$. (d) $\tilde{\alpha} = -0.2$. (e) $\tilde{\alpha} = -0.5$. (f) $\tilde{\alpha} = -1$.

FIG. 4. Determination of the roughening transition temperature T_R (Eq. 4.1). (a) $\alpha = 0.5$. $H/\epsilon = 0.2$ (dashed), $H/\epsilon = 0.1$ (dotted), $H/\epsilon = 0$ (thick solid), $H/\epsilon = -0.1$ (two-dot dashed), and $H/\epsilon = -0.2$ (dot dashed). (b) $\alpha = 1.0$. $H/\epsilon = 0.02$ (dashed), $H/\epsilon = 0.01$ (dotted), $H/\epsilon = 0$ (thick solid), $H/\epsilon = -0.01$ (two-dot dashed), and $H/\epsilon = -0.02$ (dot dashed). (c) $\alpha = 1.1$. $H/\epsilon = -0.0685$ (dashed), $H/\epsilon = -0.0735$ (dotted), and $H/\epsilon = -0.0785$ (dot dashed). The horizontal line (thin solid) corresponds to $\zeta_R = \epsilon^{\text{eff}}/k_B T = 0.633$.

FIG. 5. Phase diagram. (a) $\alpha = 0.5$. (b) $\alpha = 1.0$. (c) $\alpha = 1.1$. (d) $\alpha = 1.2$.

FIG. 6. (a) Temperature dependence of the $f(p)/k_B T$. (b) Temperature dependence of the Andreev free energy $f(\eta)$ for $\alpha = 0.5$ and $H = 0$. From top to bottom, $k_B T/\epsilon = 0.4, 0.6, 0.8, 1.0$ and 1.2 .

FIG. 7. PWFRG results for the p - η curves ($\alpha = 0.5$, and $H = 0$). Temperature of each curve is $k_B T/\epsilon = 0.4, 0.6, 0.8, 1, 1.2$, and 1.4 , from right to left.

FIG. 8. p -dependence of M_x (solid) and M_y (dashed) for $\alpha = 0.5$ and $H = 0$. From top to bottom at $p = 0$, $k_B T/\epsilon = 1.1, 0.8$ and 0.5 .

FIG. 9. Temperature-dependence of the step tension γ (Eq. (5.16)). Open circles correspond to PWFRG calculation for $\alpha = 0.5$ and $H = 0$. We draw the line for $H/\epsilon = 0.2$ (dashed), $H/\epsilon = 0.1$ (dotted), $H/\epsilon = 0$ (solid), $H/\epsilon = -0.1$ (two-dot dashed), and $H/\epsilon = -0.2$ (dot dashed). (a) $\alpha = 0.1$. (b) $\alpha = 0.5$.

FIG. 10. Temperature-dependence of the step stiffness $\tilde{\gamma}$ (Eq. (5.17)). Open circles correspond to PWFRG calculation for $\alpha = 0.5$ and $H = 0$. We draw the line for $H/\epsilon = 0.2$ (dashed), $H/\epsilon = 0.1$ (dotted), $H/\epsilon = 0$ (solid), $H/\epsilon = -0.1$ (two-dot dashed), and $H/\epsilon = -0.2$ (dot dashed). (a) $\alpha = 0.1$. (b) $\alpha = 0.5$.

FIG. 11. Temperature-dependence of the step tension γ (Eq. (5.16) and (3.5)) in the lattice gas representation. We draw the line for $H/\tilde{\epsilon} = 0.2$ (dashed), $H/\tilde{\epsilon} = 0.1$ (dotted), $H/\tilde{\epsilon} = 0$ (solid), $H/\tilde{\epsilon} = -0.1$ (two-dot dashed), and $H/\tilde{\epsilon} = -0.2$ (dot dashed). (a) The upper group of the line corresponds to $\tilde{\alpha} = -0.2$ and the lower group to $\tilde{\alpha} = 0.2$. (b) The upper group of the line corresponds to $\tilde{\alpha} = -0.5$ and the lower group to $\tilde{\alpha} = 0.5$.

FIG. 12. Temperature-dependence of the step stiffness $\tilde{\gamma}$ (Eq. (5.17) and (3.5)) in the lattice gas representation. We draw the line for $H/\tilde{\epsilon} = 0.2$ (dashed), $H/\tilde{\epsilon} = 0.1$ (dotted), $H/\tilde{\epsilon} = 0$ (solid), $H/\tilde{\epsilon} = -0.1$ (two-dot dashed), and $H/\tilde{\epsilon} = -0.2$ (dot dashed). (a) The upper group of the line corresponds to $\tilde{\alpha} = -0.2$ and the lower group to $\tilde{\alpha} = 0.2$. (b) The upper group of the line corresponds to $\tilde{\alpha} = -0.5$ and the lower group to $\tilde{\alpha} = 0.5$.

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